

URinc

University of Rochester Integrated Nanosystems Center
Goergen/Wilmot Complex River Campus Rochester, NY 14627

Description

Tool: Zeiss Auriga SEM/FIB

Location: Wilmot 206

In Service Date: 8-2010

Purpose of Tool: High resolution imaging, x-ray compositional analysis, Focused ion beam etching, TEM sample prep, ion assisted metal deposition

Materials:

Substrate: Varies

Depositions: Pt

Gases: N₂(vent), mo-Pt

Other:

Procedures: Varies

Typical Results: Nanofabrication, high resolution images

Limitations: Sample size, vacuum compatibility, electrical conductivity

Special Considerations: Chamber geometry and sample manipulation

Training Required for Use? Yes

Recipes? Yes

Engineer in Charge: Brian McIntyre

Generalized Procedure for Operating the Auriga SEM/FIB

- A. if system is in standby (yellow button) push green button
- B. if system is in off state (red button) call Brian
- C. otherwise:
 - Startup computer (poweruser (UN) and sem (PW))
 - Load smartSEM
 - Use YOUR username and password
 - Start PIP camera view
 - Put sample(s) on sample stage (wear a glove)
 - Open STAGE POINTS LIST and double click on \$exchange
 - VENT airlock
 - Place sample stage on airlock platform and screw in sample exchange rod
 - Close airlock door
 - Push TRANSFER button
 - When gate valve opens push sample rod (by white disc) onto the stage dovetail (it should mate easily; if not check sample mount pins.)
 - Unscrew and retract sample exchange rod to its park position
 - Push STORE button
 - Push RESUME button on keyboard
 - Move stage as appropriate (BE CAREFUL)
 - Turn on high voltage (EHT on)
 - Adjust EHT (double click on data field entry)
 - View samples

Record images

- Choose store resolution
- Choose slow scan rate (>8)
- Push freeze button
- Right click on image
 - Store a tiff or jpeg as desired

Shutdown when you're done

- ALL-→EHT off
- Move samples with Z to a low position
- Push EXCHANGE button on keyboard
- Push Transfer button on airlock
- Insert exchange rod and screw into stage. Pull out to park position.
- Push VENT button
- Remove sample stage and samples
- Close airlock and push STORE button
- Quit smartSEM

Notes: EDS intersection distance is now 5mm
STEM or FIB operation require specific training by Brian

Brian's home#: 394-0572
Cell#: 301-3145